Nine Men Chosen For Junior Honors Group

High Ranking Students Freed From Routine Work
Selection of nine members of the Sophomore class as members of the Junior Honors Group in the field of electrical engineering was announced today.

These students who were chosen on the basis of superior academic achievement and responsibility to work under the honors group plan are: Lewis F. Hofschneider, 97; Ralph E. Fianders, 97; Frank K. Reitz, Jr., 97; Alfred C. Schroeder, Westmount, Quebec; Joseph F. Wiggin, Scarsdale, N.Y.; Phillip F. Peters, Chicago, Ill.; Alford C. Schoerner, Worcester, Mass.; and Charles E. Bartlett, Newton, Mass.

The nine men of the honors group enter a field of engineering at Technology which is rapidly changing. By the time the class of '05 are working in the profession, the purely technical positions will be in the hands of the professional engineers and the students of the class will be finding their place in the executive posts.

The trend is toward general knowledge and while the engineering student may at first be tempted to majors in his subject, he is well advised to study a field which he may enjoy and to keep himself informed of the greater world of which he is a part.

Among the students in the early history of the School are given considerable freedom from class attendance and routine assignments. Each student chooses on his own initiative, with the advice and guidance of members of the faculty. The arrangement is designed to foster originality, intellectual courage, and self-confidence.

New Plan of Alumni Gathering Marks First Annual Reunion Day Yesterday

Marking the first annual reunion for alumni of the Illinois Institute of Technology, the New Plan of Alumni Gathering was inaugurated.

The New Plan of Alumni Gathering was marked by the attendance of a number of notables who have been affiliated with the Institute in various capacities.

Among those who attended were: Louis J. Sullivan, the noted architect; Daniel Chester French, the noted sculptor; and A. Lawrence Lowell, President of the Harvard University.

In his address, Mr. Sullivan said: "The Illinois Institute of Technology is a great enterprise. Fifteen members of the Institute's Alumni Board, which is responsible for the success of the Institute, were Technology alumni who held the posts of president of the Alumni Board, vice-president, and secretary. At least three of the alumni who served on the board were members of the Alumni Board.

The Institute leads all other colleges in the number of men listed in "Who's Who in Engineering." Among the students in the early history of the School are given considerable freedom from class attendance and routine assignments. Each student chooses on his own initiative, with the advice and guidance of members of the faculty. The arrangement is designed to foster originality, intellectual courage, and self-confidence.

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